



**PATENT**  
**30205/37328**

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Application of: Min Ho Jung et al.

Serial No.: 09/878,803

**Filed: June 11, 2001**

For: Additive for Photoresist  
Composition for Resist Flow Process

Group Art Unit: 1752

Examiner: Yvette C. Thornton

I hereby certify that this paper and the documents referred to as enclosed therewith are being deposited with the United States Postal Service as first class mail, postage prepaid, on **February 27, 2004**, in an envelope addressed to Commissioner for Patents, P.O. Box 1450, Alexandria, Virginia 22313-1450

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**SECOND AMENDMENT AFTER FINAL (37 C.F.R. § 1.116)**

Commissioner for Patents  
P.O. Box 1450  
Alexandria, Virginia 22313-1450

Sir:

Please enter the following amendment in the above-referenced patent application.

DO  
Not  
enter  
3-11-04  
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